



IPW

PATENT

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 21313-1450 on February 22, 2006

Katie Hales
Katie Hales

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/715,758

Attorney Docket: DP-302242 DIV

Filing Date: 11/18/2003

Group Art Unit: 1763

Applicant: David B. Rich et al.

Examiner: Kwok, Helen C.

Title: DEEP REACTIVE INO ETCHING PROCESS AND
MICROELECTROMECHANICAL DEVICES FORMED THEREBY

MS Fee/Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

AMENDMENT

Sir:

In response to the Office Action mailed November 22, 2005, please amend the subject application and consider the remarks set forth herein.

I. Amendment to the Claims

Page 2

II. Remarks

Page 5